

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application.

Listing of Claims:

1. (Currently Amended) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element and a capacitive element connected in series with said switching element,

wherein said capacitive element has a ferroelectric body, and at least 80% of said ferroelectric body has a polarization axis within 5 degrees of a predetermined direction of an electric field across said capacitive element, and

wherein said capacitive element is provided above said switching element,

and the ratio of the electrode area of the capacitor to the whole top plan area of the memory element is ~~as low as~~ 30% or less.

2. (Currently Amended) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element, said switching element having a first electrode, a second electrode and a gate electrode, and a capacitive element connected to said first electrode in series with said switching element,

wherein said capacitive element has a ferroelectric body, and at least 80% of said ferroelectric body has a polarization axis within 5 degrees of a predetermined direction of an electric field across said capacitive element, and

wherein said ferroelectric body is provided above said first electrode,
and the ratio of the electrode area of the capacitor to the whole top plan area of the memory element is ~~as low as~~ 30% or less.

3. (Original) A semiconductor memory device according to claim 1 or 2, wherein said ferroelectric body is comprised of a plurality of ferroelectric crystals and each of said crystals has a surface parallel to said polarization axis.

4. (Original) A semiconductor device comprising:
a substrate,
a connector attached to the substrate, and
a plurality of memories provided on the substrate,
wherein each of the memories includes a semiconductor memory device according to claim 1 or 2.

5. (Original) A semiconductor device according to claim 4, wherein the semiconductor device is a semiconductor disk.

6. (Original) A semiconductor device according to claim 4, wherein the semiconductor device is a semiconductor memory card.

7. (Original) A microprocessor including a cache memory having the semiconductor memory device according to claim 1 or claim 2.

8. (Original) A computer system comprising:
a microprocessor,
a memory, and
a system bus to which said microprocessor and said memory are connected,
wherein said microprocessor includes a cache memory having the
semiconductor memory device according to claim 1 or claim 2.

9 (Original) A computer system comprising:
a microprocessor,
a memory, and
a system bus to which said microprocessor and said memory are connected,
wherein said memory includes the semiconductor memory device according
to claim 1 or claim 2.

10. (Original) A computer system comprising:
a microprocessor,
a memory connected to said microprocessor, and
an I/O control connected to said microprocessor,
wherein said microprocessor includes a cache memory having the
semiconductor memory device according to claim 1 or claim 2.

11. (Original) A computer system comprising:
a microprocessor,
a memory connected to said microprocessor, and

an I/C control connected to said microprocessor,
wherein said memory includes the semiconductor memory device according to claim 1 or claim 2.

12. (Original) An engine control apparatus comprising:
an I/O control,
a microprocessor connected to said I/O control, and
a memory connected to said I/O control,
wherein an engine is controlled via said I/O control by said microprocessor and said memory, and
wherein said microprocessor includes a cache memory having the semiconductor memory device according to claim 1 or claim 2.

13. (Original) An engine control apparatus comprising:
an I/O control,
a microprocessor connected to said I/O control, and
a memory connected to said I/O control,
wherein an engine is controlled via said I/O control by said microprocessor and said memory, and
wherein said memory includes the semiconductor memory device according to claim 1 or claim 2.

14. (Original) An engine control apparatus according to claim 12, wherein said engine is installed in any one of a vehicle, an air craft, an artificial satellite, a space station and a rocket.

15. (Original) An engine control apparatus according to claim 13, wherein said engine is installed in any one of a vehicle, an air craft, an artificial satellite, a space station and a rocket.

16. – 17. (Cancelled)

18. (New) A method of controlling an engine which is coupled to a microprocessor, an I/O control and a memory, wherein said memory includes a switching element and a capacitive element connected in series with said switching element, wherein said capacitive element has a ferroelectric body, and at least 80% of said ferroelectric body has a polarization axis within 5 degrees of a predetermined direction of an electric field across said capacitive element, and wherein said capacitive element is provided above said switching element, said method comprising:

controlling said engine by said microprocessor and said memory through said I/O control by detecting a change in polarization of the ferroelectric capacitor when a voltage is applied which is not sufficient to cause a change of state of the ferroelectric capacitor.

19. (New) A method according to claim 18, wherein a plurality of said ferroelectric capacitors are connected to said switching element, said method further comprising:

writing different data into different ones of said ferroelectric capacitors.

20. (New) A method according to claim 18, wherein the ratio of the electrode area of the capacitor to the whole top plan area of the memory element is 30% or less.

21. (New) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element and a capacitive element connected in series with said switching element,

wherein said capacitive element has a ferroelectric body, and at least 80% of said ferroelectric body has a polarization axis within 5 degrees of a predetermined direction of an electric field across said capacitive element, and

wherein said capacitive element is provided above said switching element.

22. (New) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element, said switching element having a first electrode, a second electrode and a gate electrode, and a capacitive element connected to said first electrode in series with said switching element,

wherein said capacitive element has a ferroelectric body, and at least 80% of said ferroelectric body has a polarization axis within 5 degrees of a predetermined direction of an electric field across said capacitive element, and
wherein said ferroelectric body is provided above said first electrode.

23. (New) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element and a capacitive element connected in series with said switching element, wherein said capacitive element has a ferroelectric body, and the polarization axis of said ferroelectric body is substantially parallel to a predetermined direction of an electric field across said capacitive element, and wherein said capacitive element is provided above said switching element,

and the ratio of the electrode area of the capacitor to the whole top plan area of the memory element is 30% or less.

24. (New) A semiconductor memory device having at least one memory cell, said at least one memory cell including a switching element, said switching element having a first electrode, a second electrode and a gate electrode, and a capacitive element connected to said first electrode in series with said switching element, wherein said capacitive element has a ferroelectric body, and the polarization axis of said ferroelectric body is substantially parallel to a predetermined direction of an electric field across said capacitive element, and wherein said ferroelectric body is provided above said first electrode,

and the ratio of the electrode area of the capacitor to the whole top plan area of the memory element is 30% or less.